

查询CP221供应商
PROCESS CP221
Small Signal Transistor
NPN- High Voltage Darlingtion Transistor Chip

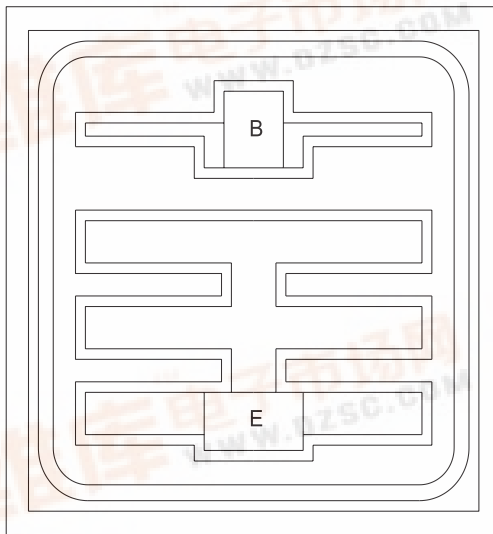
捷多邦，专业PCB打样工厂，24小时加急出货™

Central
Semiconductor Corp.

PROCESS DETAILS

Process	EPITAXIAL BASE
Die Size	39.5 X 39.5 MILS
Die Thickness	9.8 MILS
Base Bonding Pad Area	3.9 x 5.1 MILS
Emitter Bonding Pad Area	7.9 x 3.9 MILS
Top Side Metalization	Al - 24,000Å
Back Side Metalization	Au - 12,000Å

GEOMETRY



BACKSIDE COLLECTOR

R0

GROSS DIE PER 4 INCH WAFER

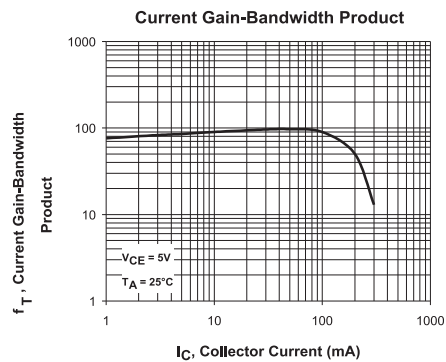
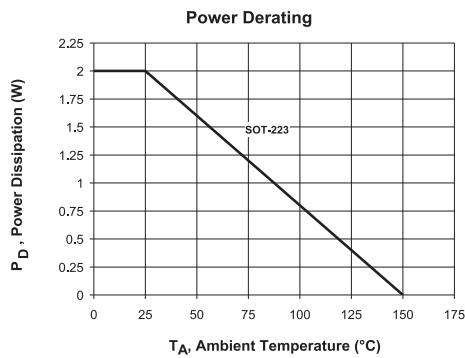
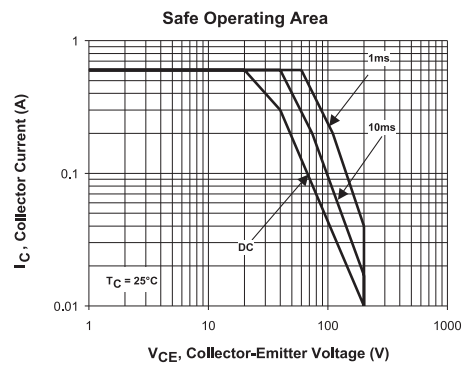
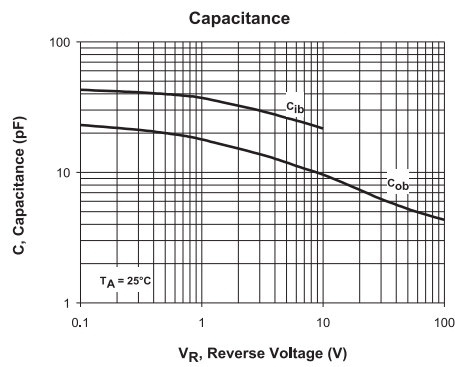
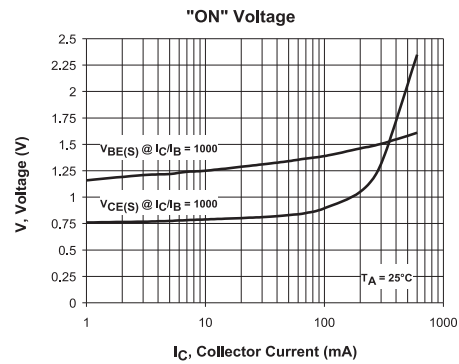
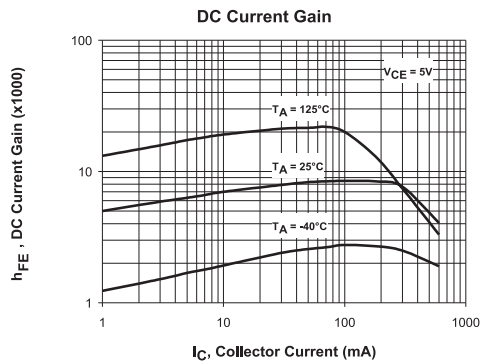
7,290

PRINCIPAL DEVICE TYPES

CZT2000

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R1 (1-August 2002)



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